

Grounded-surface PP-NP-P+ Double Junction type Solar Cell
JPA2020-13131 by Yoshiaki Hagiwara AIPS

SONYのBIPOLAR TRANSISTOR生産技術には KOH液によるSilicon のEtchingが鍵でした。

[How to make Multi Junction Solar Cell Yoshiaki Hagiwara.html](http://How%20to%20make%20Multi%20Junction%20Solar%20Cell%20Yoshiaki%20Hagiwara.html)

